

High Cutoff Frequency Achieved in van der Waals Schottky Diodes via Air Gap Engineering

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Abstract

Radio-frequency (RF) electronics operating from the MHz to sub-THz range are becoming increasingly important for next-generation technologies such as 5G/6G communications. Among emerging electronic materials, two-dimensional van der Waals materials have attracted significant attention for RF devices due to their unique electronic properties and potential for ultrahigh-frequency operation [1-2].

In this work, we investigate ultrahigh cutoff frequency (f_c) characteristics of a vertical van der Waals Schottky diode based on rhenium diselenide (ReSe_2) using air-gap engineering at the Ohmic contact interface. By air-gap engineering, capacitance is significantly modulated, resulting in enhanced high-frequency performance. The fabricated devices exhibit intrinsic cutoff frequencies up to 430 GHz, among the highest reported for thin-film-based RF diodes.

As the air-gap size increases, the intrinsic f_c improves from approximately 30 GHz in conventional structures to 310–430 GHz in air-gap-engineered devices. Also, equivalent circuit analysis shows good agreement with the experimental results and reveals that the air-gap structure effectively modulates the capacitance while maintaining rectifying characteristics. In addition, RF rectifier circuits demonstrate an increase in extrinsic f_c from 2 GHz to 40 GHz. These results suggest strong potential of high-frequency RF electronics based on two-dimensional van der Waals materials [3].

References

- [1] Yang, Sung Jin, et al. Nature communications 11 (2020) 1574.
- [2] Hong, Sungjae, et al. Science Advances 9 (2023) eadh9770.
- [3] Hong, Sungjae, et al. Advanced Functional Materials (2026): e27171.

Figures

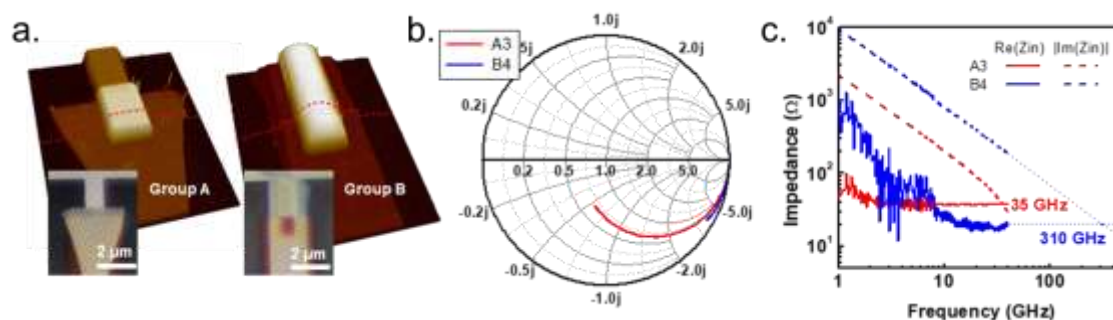


Figure 1: (a) Flat diode and Air-gap diode's AFM Image and back side OM image. (b) Smith chart RF characteristics and (c) S_{11} parameter with Cut off frequency of Flat diode and Air-gap diode.